

Scholarship Opportunity for Postgraduate Students: KAS (Germany) International Scholarship

Dear students,

The International Office is pleased to share a compelling postgraduate scholarship opportunity from **Konrad-Adenauer-Stiftung (KAS)** -- the **International Talent Development Program**. This program is intended for outstanding Malaysian students who plan to pursue a full-time postgraduate degree in Germany. It is designed to support individuals with strong academic potential, active community involvement, and a genuine interest in current public affairs, leadership, and human rights.

Selected scholars may receive financial support of **up to EUR 992 per month for a 2-year Master's program** or up to **EUR 1,400 per month for a PhD program**, together with access to training sessions, KAS events, publications, expert engagement, mentoring, and exposure to international network.

Applicants must:

- Have **German language proficiency** at minimum **B2 level** (e.g. Goethe-Institut certificate or equivalent)
- Demonstrate **above-average academic performance**
- Show active community involvement / volunteer work
- Demonstrate motivation, critical thinking, and a clear interest in social and political issues

Important Dates

- **Application deadline** (if applying from within Germany): **15 July, 12:00 noon (CET)** each year
- **Applications from abroad:** through the relevant **KAS overseas office**, subject to that office's annual schedule
- **Selection process:** follows KAS's published procedure and may vary depending on the application route

Interested students are strongly encouraged to review the eligibility criteria carefully and prepare their application well in advance. This is an excellent opportunity to build your academic profile, broaden your international exposure, and join a global community of KAS scholars.

For further information on full details on funded courses, eligibility and application requirements, visit [KAS website](#), or contact stipendium-if@kas.de.

Warm regards,

International Office @USM